Name:

Enrolment No:



UNIVERSITY OF PETROLEUM AND ENERGY STUDIES

End Semester Examination, December 2021

Course: Nanomaterial Processing and Application Program: B. Tech Mechanical Course Code: MEMA4005P

Semester: VII Time 03 hrs Max. Marks: 100

Instructions:

	SECTION-A: Total 20 marks	
	Each question carries 4 marks	-
S. No.		СО
Q 1	What are the unique properties of Kevlar and what are it's applications? (4)	CO2
Q 2	What do you understand by the term 'dangling bonds' and how is it related to the origin of surface energy? (4)	CO1
Q 3	Mention any two mechanisms through which nanomaterials can reduce their surface energy. (4)	CO2
Q 4	Draw a schematic potential energy curve to show the interaction between two atoms separated by any distance (r). (4)	CO1
Q 5	Briefly discuss the sol-gel method for synthesis of nanoparticles. (4)	CO3
	SECTION-B : Total 40 marks	•
	Each question carries 10 marks	
	variation of free energy as a function of size of nanoparticle (r). $\Delta G = 4\pi r^2 \gamma$ $\Delta G = (4/3)\pi r^3 \Delta G_v + 4\pi r^2 \gamma$ $\Delta G = (4/3)\pi r^3 \Delta G_v + 4\pi r^2 \gamma$ $\Delta G = (4/3)\pi r^3 \Delta G_v$ Answer the following: a) From the graph, identify the smallest sized stable nanoparticle that can be created through homogenous nucleation. (2) b) Derive an expression for this critical size as a function of ΔG_v and γ . (4) c) Briefly discuss four ways in which this critical size can be reduced to enable formation	CO3

Q 7 Using a schematic, briefly discuss the differences between the three types of growth: Island growth, Layer growth and Island-layer growth. (10)	CO3
Q 8Using a schematic, briefly discuss the sputtering process used for depositing thin films on a substrate. (10)	CO4
 Q 9 The figure below shows various atomic positions (1 to 5) in Terrace-Ledge-Kink (TLK) model that is used to describe thermodynamics of crystal surface formation. 3 4 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1	CO4
SECTION-C: Total 40 marks	
Q 10 The figure below shows the formation of silicon nanorods (Si-whisker) through Vapour-Liquid-Solid (VLS) growth process. SiCl ₄ + 2H ₂ → Si + 4HCl ↓ ↓ ↓ ▲u-Si Bilicon Substrate Answer the following: a) VLS process requires use of a second-phase material (catalyst or impurity). Identify the second-phase material that has been used in above figure. (2) b) Briefly describe the growth process of Si nanorods as shown in above figure (8). c) In VLS process, discuss the role of wetting angle in controlling the diameter of nanowires (5). d) In VLS process, the equilibr	CO3

